國立中正大學100學年度碩士班招生考試試題系所別:光機電整合工程研究所 科目:半導體元件物理

第3節

第/頁,共/頁

- 1. (25分) Please derive the ideal current-voltage relation in the nonsaturation and saturation region for the n-channel MOSFET.
- 2. (25 分) Please sketch the ideal energy-band diagrams (before and after "ohmic" contact) for (a) an ideal metal-to-n-type semiconductor junction, and (b) an ideal metal-to-p-type semiconductor junction. (please label the following terms: E_c, E_v, E_F, E_{Fi}, eφ_m, eφ_n, eφ_p, eφ_s, eφ_{Bn}, φ_{Bp}, e χ)
- 3. (25 分) Explain the following items:
 - (a) Fermi-Dirac distribution function
 - (b) Phonon
 - (c) Stimulated emission
 - (d) Photovoltaic effect
 - (e) Avalanche breakdown in junction diode
- 4. (25 分)(a) Plot the electron mobility versus temperature relation for typical n-type silicon, and explain why that?
 - (b) Plot the electron concentration versus temperature relation for typical n-type silicon, and explain why that?